



Sheet 1 of 1

FORM PTO-1449	U.S. DEPARTMENT OF COMMERCE PATENT AND TRADEMARK OFFICE	ATTORNEY DOCKET NO. 0862.1463	APPLICATION NO. 09/890,143
<b>INFORMATION DISCLOSURE STATEMENT</b> <i>(Use several sheets if necessary)</i>		FIRST NAMED INVENTOR Masaki YAMAMOTO	
		FILING DATE July 26, 2001	GROUP ART UNIT 2882

**U.S. PATENT DOCUMENTS**

*EXAMINER INITIAL		DOCUMENT NO.	DATE	NAME	CLASS	SUB- CLASS	FILING DATE
	AA	5,935,737	8/10/1999	Yan			
	AB	5,085,957	2/4/1992	Hosono			
	AC						
	AD						
	AE						
	AF						

**FOREIGN PATENT DOCUMENTS**

		DOCUMENT NO.	DATE	COUNTRY	<u>TRANSLATION</u> YES NO		ABSTRACT
	AG	EP 0 279 670	8/24/1988	Europe			
	AH	4-204603	7/27/1992	Japan			X
	AI	6-180399	6/28/1994	Japan			X
	AJ	11-23796	1/29/1999	Japan			X
	AK	63-211130	9/2/1988	Japan			X
	AL						

**OTHER REFERENCES (Including Author, Title, Date, Pertinent Pages, Etc.)**

				<u>TRANSLATION</u> YES NO	
	AM	Hawryluk et al., "Repair of Opaque Defects on Reflection Masks for Soft X-Ray Projection Lithography", J. Vac. Sci. Technol. B 10(6), Nov/Dec. 1992, pgs. 3182-3185.			

EXAMINER  /Chih-Cheng Kao/	DATE CONSIDERED  08/18/2008
*EXAMINER: Initial if reference considered, whether or not citation is in conformance with MPEP 609. Draw line through citation if not in conformance and not considered. Include copy of this form with next communication to applicant.	